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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/600,531	06/23/2003	Katsura Nakajima	D-1507	5799
7590 06/15/2004			EXAMINER	
KANESAKA AND TAKEUCHI			BOUTSIKARIS, LEONIDAS	
1423 Powhatan Street Alexandria, VA 22314			ART UNIT	PAPER NUMBER
Thomasan, VII 2251.			2872	
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Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)			
Office Action Cummen.	10/600,531	NAKAJIMA ET AL.			
Office Action Summary	Examiner	Art Unit			
	Leo Boutsikaris	2872			
The MAILING DATE of this communication appears on the cover shet with the correspondence address Period for Reply					
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).  Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).					
Status					
1)⊠ Responsive to communication(s) filed on 23 June 2003.					
2a) ☐ This action is <b>FINAL</b> . 2b) ☑ This	This action is FINAL. 2b)⊠ This action is non-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims					
4)⊠ Claim(s) <u>1-8</u> is/are pending in the application.					
4a) Of the above claim(s) is/are withdrawn from consideration.					
5) Claim(s) is/are allowed.					
6)⊠ Claim(s) <u>1-8</u> is/are rejected.					
7) Claim(s) is/are objected to.					
8) Claim(s) are subject to restriction and/or	election requirement.				
Application Papers					
9)  The specification is objected to by the Examiner.					
10)⊠ The drawing(s) filed on <u>23 June 2003</u> is/are: a)⊠ accepted or b)⊡ objected to by the Examiner.					
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).  11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.					
Priority under 35 U.S.C. § 119					
12)⊠ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).					
a) ☐ All b) ☐ Some * c) ☒ None of:  1.☒ Certified copies of the priority documents have been received.					
2. Certified copies of the priority documents have been received in Application No					
3. Copies of the certified copies of the priority documents have been received in this National Stage					
application from the International Bureau (PCT Rule 17.2(a)).					
* See the attached detailed Office action for a list of the certified copies not received.					
Attachment(s)					
1) Notice of References Cited (PTO-892)  4) Interview Summary (PTO-413)					
<ul> <li>2) Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)</li> <li>Paper No(s)/Mail Date</li></ul>	Paper No(s)/Mail Da 5) Notice of Informal Pa 6) Other:	te atent Application (PTO-152)			

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#### **DETAILED ACTION**

#### **Priority**

Acknowledgment is made of applicant's claim for foreign priority based on an application filed in Japan on 6/28/2002. It is noted, however, that applicant has not filed a certified copy of the said application as required by 35 U.S.C. 119(b).

## Claim Objections

Claim 5 is objected to because of the following informalities:

Claim 5 refers to chromel layer, as well as to silicon dioxide and magnesium fluoride layers, which lack antecedent basis. For examination purposes it will be taken that claim 5 depends from claim 4.

Appropriate correction is required.

### Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1 and 6-8 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kunii (US 6,671,109) in view of Biznyuk (US 2003/0008136).

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Regarding claim 1, 6-7, Kunii discloses an ND filter comprising a substrate 1 formed of a plastic sheet, e.g., PET, and a deposit film (2-6) formed on a surface of the substrate (Figs. 1-2, line 16, col. 4 to line 18, col. 5). Kunni's filter is made by depositing layers of metal oxides on the PET substrate in vacuum (see Fig. 2). Kunni does not specify the glass transition temperature of the PET substrate, other than saying that its temperature during the deposition process is 100 degrees (lines 19-22, col. 5). Biznyuk discloses a method of depositing a first polymer material on a polymer substrate, such as a PET layer. During the deposition process, the temperature of the PET substrate must be raised to a certain degree. Biznyuk teaches that whatever that substrate temperature during the deposition process is, it must be lower than the glass transition temperature of the PET substrate ([0008]-[0010], [0044]). It would have been obvious to one of ordinary skill in the art to choose a plastic material for the substrate for making the ND filter of Kunii, such that the plastic material has a glass transition temperature higher than the deposition temperature, as taught by Bliznyuk, for avoiding changes in the physical properties of the substrate during the deposition process. Furthermore, it would have been obvious to one of ordinary skill in the art to choose the threshold for the glass transition temperature at 120 degrees for the plastic substrate, since it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or workable ranges involves only routine skill in the art. In re Aller, 220 F.2d 454, 456, 105 USPQ 233, 235. Here, the prior art suggests that the glass transition temperature of the plastic substrate must be at least higher than 100 degrees. Choosing a threshold of 120 degrees represents a point, which is far enough from the deposition temperature to avoid phase change problems, yet not too high which would be difficult to accomplish for a plastic material.

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Regarding claim 8, the ND filter of Kunii is used as part of an aperture device in a camera (Fig. 9).

Claims 1, 6-8 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yoshikawa (JP 10-133253) in view of Biznyuk (US 2003/0008136).

Regarding claim 1, 6-7, Yoshikawa discloses an ND filter comprising a substrate formed of a plastic sheet, e.g., PET or PEN, and a deposit film (MgF<sub>2</sub> or SiO<sub>2</sub>) formed on a surface of the substrate (Fig. 3). The filter is made by depositing the layers of metal oxides on the PET substrate in vacuum ([0010]). Yoshikawa does not specify the glass transition temperature of the PET substrate, other than saying that PET or PEN has a glass transition temperature, which is factor in choosing the material ([0010]). Biznyuk discloses a method of depositing a first polymer material on a polymer substrate, such as a PET layer. During the deposition process, the temperature of the PET substrate must be raised to a certain degree. Biznyuk teaches that whatever that substrate temperature during the deposition process is, it must be lower than the glass transition temperature of the PET substrate ([0008]-[0010], [0044]). It would have been obvious to one of ordinary skill in the art to choose a plastic material for the substrate for making the ND filter of Yoshikawa, such that the plastic material has a glass transition temperature higher than the deposition temperature, as taught by Bliznyuk, for avoiding changes in the physical properties of the substrate during the deposition process. Furthermore, it would have been obvious to one of ordinary skill in the art to choose the threshold for the glass transition temperature at 120 degrees for the plastic substrate, since it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or workable ranges

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involves only routine skill in the art. *In re Aller*, 220 F.2d 454, 456, 105 USPQ 233, 235. Choosing a threshold of 120 degrees represents a point, which is far enough from the deposition temperature to avoid phase change problems, yet not too high which would be difficult to accomplish for a plastic material.

Regarding claim 8, the ND filter of Yoshikawa is used as part of an aperture device in a camera (Fig. 1).

# **Double Patenting**

The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. See *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970);and, *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent is shown to be commonly owned with this application. See 37 CFR 1.130(b).

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

Claims 1-8 are provisionally rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 1-3, 6 of copending Application No. 10/600528. Although the conflicting claims are not identical, they are not patentably distinct from each other because they are drawn to an ND filter comprising a norbornene resin substrate, with alternating Chromel and silicon dioxide layers deposited on top of the substrate, with a magnesium fluoride layer formed on top. It is noted that a norbornene

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resin material has glass transition temperature of at least 120 degrees (see [0019] in specification).

This is a <u>provisional</u> obviousness-type double patenting rejection because the conflicting claims have not in fact been patented.

#### Allowable Subject Matter

Claims 2-5 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims, provided that the Double Patenting rejection set forth in this Office Action is overcome, and if claim 5 overcomes the objection set forth in the present Office Action.

Claims 2-5 are allowable over the prior art for at least the reason that even though the prior art discloses ND filters comprising plastic substrates with metallic or metal oxide layers deposited thereupon, the prior art fails to teach or reasonably suggest an ND filter comprising a wherein the plastic sheet has 0.5% or less of turbidity, as set forth by the claimed combination.

Amano (US 5,715,103, Fig. 6A) discloses an ND filter comprising a transparent substrate with metal oxide layers formed thereupon. Zhang (US 5,726,797, Fig. 2A) discloses an ND filter having a dielectric substrate and a film composed of an alloy of copper and nickel. Finally, Tuthill (US 3,897,140, Fig. 1) discloses a solar filter comprising a resin substrate having a metal layer formed thereupon. Finally, Yanagi (US 2004/0021967) discloses am ND filter made by vacuum deposition, where it is taught that PET is selected as substrate because of its high value of glass transition temperature ([0149]).

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dr. Leo Boutsikaris whose telephone number is 571-272-2308.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Leo Boutsikaris, Ph.D. Patent Examiner, AU 2872

June 13, 2004